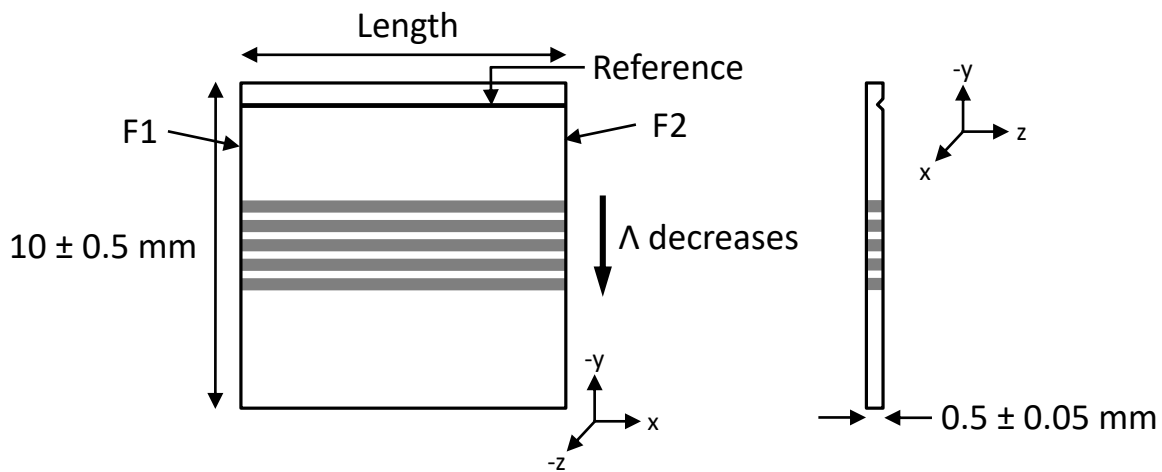


# Device Specification

## MSFG647-0.5-xx



[Image for reference only. Not to scale.]

Description MgO doped PPLN SFG crystal for 1550.12nm and 1109.68nm generating 646.7nm  
Thickness(z)  $0.5\text{mm} \pm 0.05\text{mm}$   
Width(y)  $10\text{mm} \pm 0.5\text{mm}$   
Length(x)  $40\text{mm} \pm 0.5\text{mm}$ ,  $20\text{mm} \pm 0.5\text{mm}$ ,  $10\text{mm} \pm 0.2\text{mm}$ ,  $3\text{mm} \pm 0.1\text{mm}$ ,  $1\text{mm} \pm 0.1\text{mm}$   
Periods( $\Lambda$ ) 12.10, 12.30, 12.50, 12.70, 12.90 $\mu\text{m}$

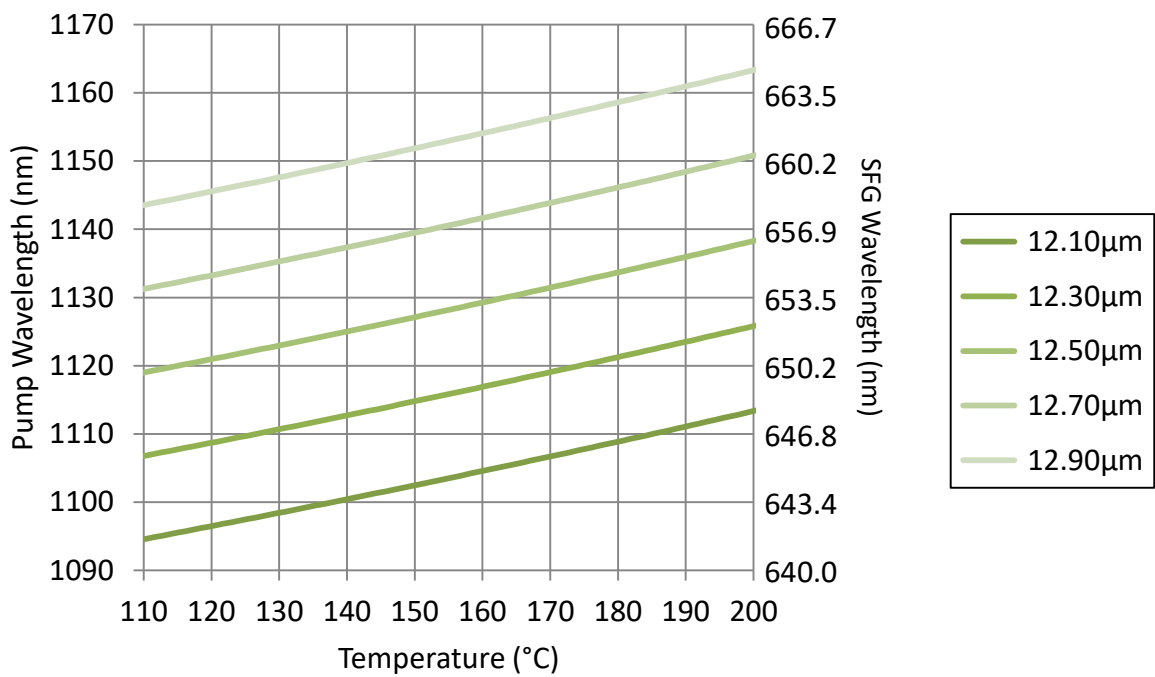
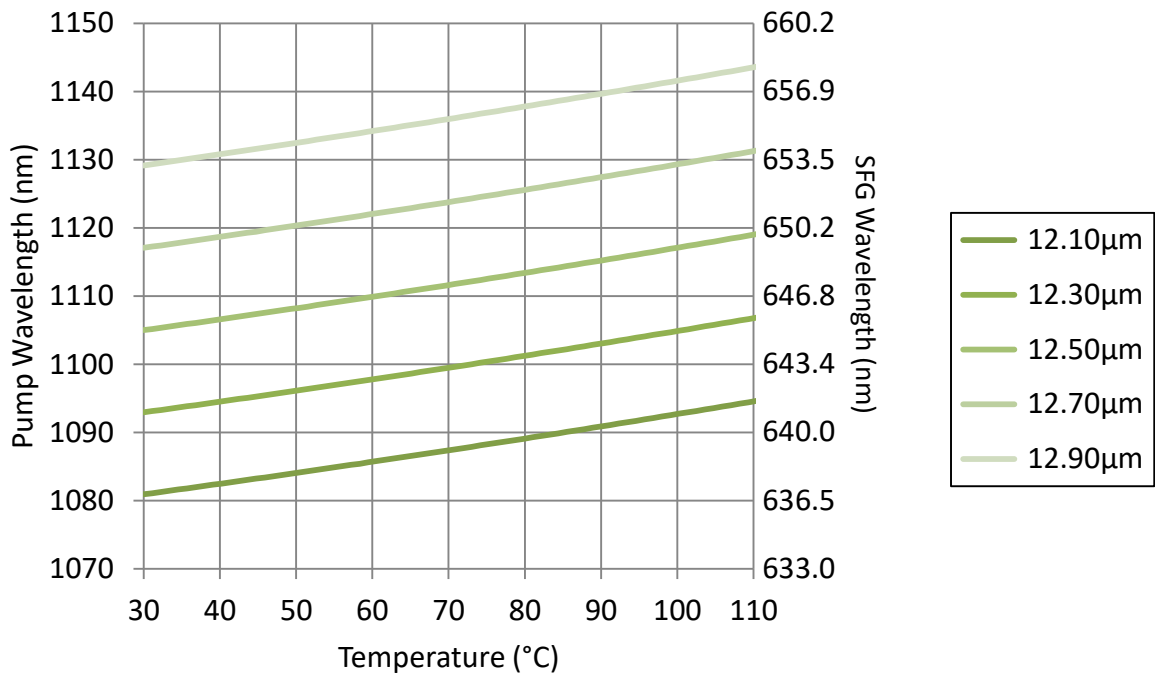
### NOTES:

- 1 The SFG device material is Magnesium doped Lithium Niobate with five periodically poled gratings. Each grating is 0.5mm wide with individual periods as listed above. A saw-cut reference mark is provided on the +z face of the crystal to determine the largest grating period (see above diagram). Each poled grating is separated by 0.2mm wide regions of unpoled material.
- 2 The average mark-to-space ratio of each grating is better than 70:30.
- 3 Each device is etched to make the poled gratings visible. Due to the wet-etch nature of this process the top and bottom surface finish of each device may appear cloudy or uneven.
- 4 Perpendicularity of input/output facets F1 and F2 to gratings is within  $\pm 0.15^\circ$ . Parallelism between end facets F1 and F2 is within  $\pm 5$  minutes.
- 5 Optical finish of facets F1 and F2 is within 20/10 scratch dig with  $\lambda/4@633\text{nm}$ . No more than two  $100\mu\text{m}$  size chips per end facet.
- 6 Triple-band AR coating to  $R < 1\%$  1110nm, 1550nm and 646.7nm on both input/output facets.

# Device Specification

## MSFG647-0.5-xx

### SFG Tuning Curve for 1550nm Pump



Please note these are calculated tuning curves only and actual values may vary.

For more information, please contact us at:

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